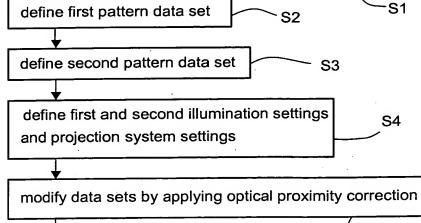


identify isolated, dense, and semi dense contact holes

define first pattern data set

write first and second mask pattern

Fig. 8



**S6** 

**S**5

